Notice of References Cited

Application/Control No.	Applicant(s)/Pater	nt Under
10/551,843	Reexamination OHMI ET AL.	
Examiner	Art Unit	
GRANT S. WITHERS	2812	Page 1 of 1

U.S. PATENT DOCUMENTS

	C.G. PATERT DOCUMENTO				
*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	Α	US-			
	В	US-			
	С	US-			
	D	US-			
	Е	US-			
	F	US-			
	G	US-		-	
	Н	US-		-	
	Т	US-			
	J	US-			
	К	US-			
	L	US-			
	М	US-			

FOREIGN PATENT DOCUMENTS

	FOREIGN FATENT DOCUMENTS					
*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	0					
	Р					
	Q					
	R					
	s					
	Т					

NON-PATENT DOCUMENTS

	THE PROPERTY OF THE PROPERTY O				
*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)			
	U	Hamelmann, F. "W/Si multilayers deposited by hot-filament MOCVD" Thin Solid Films 338 (1999) pp 70-74			
	٧				
	w				
	×				

A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)

Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.